



Docket No.: T2171.0214
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Tomoyasu Aoshima

Application No.: 10/773,244

Confirmation No.: 7164

Filed: February 9, 2004

Art Unit: 1765

For: ANISOTROPIC WET ETCHING OF
SILICON

Examiner: E. B. Chen

AMENDMENT

MS RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

This Amendment is being submitted together with a Request for Continued Examination (RCE). Prior to the issuance of the next Office Action, please enter the following amendments and remarks in the above-identified U.S. patent application.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 7 of this paper.

FEE CALCULATION

Any additional fee required has been calculated as follows:

	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate	Additional Fee
Total	20	- 20* =		x 50.00	
Independent	2	- 3** =		x 200.00	
First presentation of Multiple Dependent Claim(s) (if applicable)					
TOTAL					\$ 0.00

*not less than 20

** not less than 3

No additional fee is required.

In the event a fee is required or if any additional fee during the prosecution of this application is not paid, the Patent Office is authorized to charge any underpayment or credit any overpayment to Deposit Account No. 50-2215.

CONTINGENT EXTENSION REQUEST

If this communication is filed after the shortened statutory time period had elapsed and no separate Petition is enclosed, the Commissioner of Patents and Trademarks is petitioned, under 37 C.F.R. § 1.136(a), to extend the time for filing a response to the outstanding Office Action by the number of months which will avoid abandonment under 37 C.F.R. § 1.135. The fee under 37 C.F.R. § 1.17 should be charged to our Deposit Account No. 50-2215.